

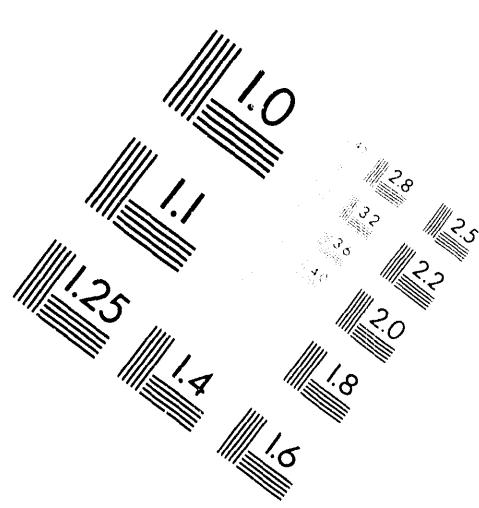
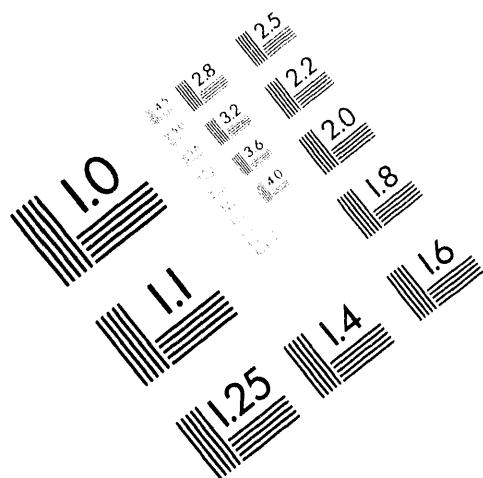


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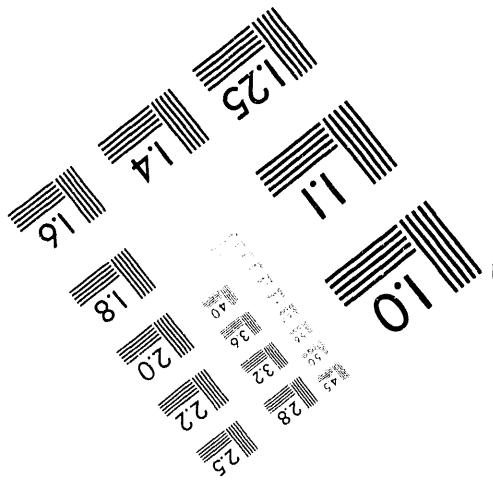
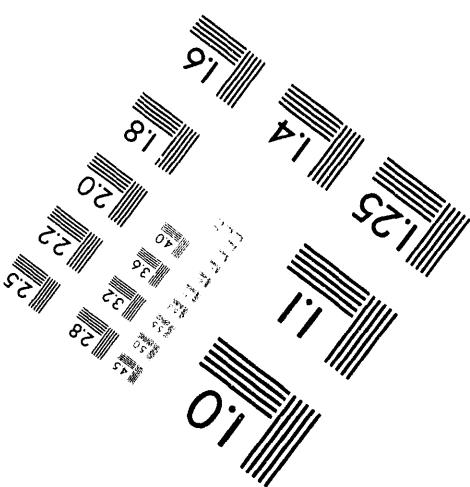
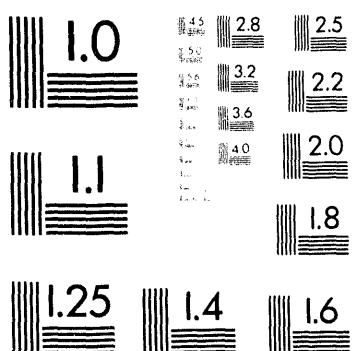
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MAGNETIC FIELD INDUCED MINIGAP  
IN DOUBLE QUANTUM WELLS

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ABSTRACT

We report the discovery of a partial energy gap, or minigap, in strongly coupled double quantum wells (QWs), due to an anticrossing of the two QW dispersion curves. The anticrossing and minigap are induced by an in-plane magnetic field  $B_{\parallel}$ , and give rise to large distortions in the Fermi surface and density of states, including a Van Hove singularity. Sweeping  $B_{\parallel}$  moves the minigap through the Fermi level, with the upper and lower gap edges producing a sharp maximum and minimum in the low-temperature in-plane conductance, in agreement with theoretical calculations. The gap energy may be directly determined from the data.

## 1. Introduction

Applying an in plane magnetic field  $B_{\parallel}$  to a double quantum well (QW) causes the canonical momenta  $k$  of electrons in one QW to be shifted relative to those in the other. The shift is given by  $\Delta k_y = edB/\hbar$ , where  $d$  is the distance between the two electron layers, and direction  $y$  is normal to both the growth and  $B_{\parallel}$  directions. Recent studies<sup>1,2</sup> have shown this to have a strong effect on interwell tunneling, due to the conservation of  $k$ . Little attention, however, has been paid to the effect of this shift on the in-plane conductance  $G_{\parallel}$ .<sup>3</sup> This is of interest since the shifted dispersion curves of two strongly coupled QWs can be expected to produce an anticrossing, resulting in a large minigap. At sufficiently high  $B_{\parallel}$  the minigap can be made to pass through the Fermi level. Under these conditions the DQW has a multi-component Fermi surface whose shape and topology is tunable by  $B_{\parallel}$ .<sup>4</sup> Our data show the presence of this minigap, and demonstrate that the electronic density of states and group velocities are dramatically distorted near its edges, producing the observed sharp features in  $G_{\parallel}(B_{\parallel})$ . By plotting the  $B_{\parallel}$ -positions of the features as a function of a surface gate voltage  $V_G$ , the gap energy can be extracted.

## 2. Experimental Set-up

Three MBE-grown structures were studied, each consisting of a modulation-doped pair of GaAs QWs of equal width  $w$  separated by an  $\text{Al}_{0.3}\text{Ga}_{0.7}\text{As}$  barrier of thickness  $t$ . Samples A, B, and C had  $w=150 \text{ \AA}$ ,  $t = 25 \text{ \AA}$ ;  $w = 100 \text{ \AA}$ ,  $t = 35 \text{ \AA}$ ; and  $w = 150 \text{ \AA}$ ,  $t =$

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15 Å, respectively. Standard four terminal low-frequency lock-in measurements were performed at  $T \geq 0.3$  K on 0.2 mm wide Hall bars with Cr/Au surface gates. At  $V_G=0$ , samples A, B, and C had top QW densities  $n_1 \approx 1.4, 1.2$  and  $0.7 \times 10^{11} \text{ cm}^{-2}$ , and bottom QW densities  $n_2 \approx 1.5, 1.2$ , and  $0.9 \times 10^{11} \text{ cm}^{-2}$ , respectively. The  $V_G=0$  mobilities of the top QW were  $\mu_1 \approx 2.7, 1.2$ , and  $0.6 \times 10^5 \text{ cm}^2/\text{Vs}$ , and of the bottom QW were  $\mu_2 \approx 2.2, 0.6$ , and  $0.2 \times 10^5 \text{ cm}^2/\text{Vs}$ , respectively.  $n_1$  and  $n_2$  were determined from quantum Hall and Shubnikov-de Haas (SdH) measurements in  $B_{\perp}$ , followed by a rotation *in situ* for measurement in  $B_{\parallel}$ , with the residual component of  $B_{\perp}$  less than 0.005 T. The applied electric field was nominally parallel to  $B_{\parallel}$ .

### 3. Effect of Anticrossing on the In-Plane Conductance

Fig. 1 shows the normalized  $G_{\parallel}(B_{\parallel})$  for several  $V_G$ . For  $V_G=0$ , a sharp maximum appears at  $B_{\max} \approx 5.8$  T, followed by a sharp minimum at  $B_{\min} \approx 6.4$  T. As  $V_G$  decreases, both features move to lower  $B_{\parallel}$ , with  $B_{\max}$  moving more rapidly than  $B_{\min}$ . The features disappear once the top QW depletes at  $V_G = -0.29$  V, since their origin is due solely to interactions between the two QWs. The maximum and minimum correspond respectively to the upper and lower edges of the minigap crossing the Fermi level.

Fig. 2 shows the results of a tight-binding calculation<sup>5</sup> for a double QW structure

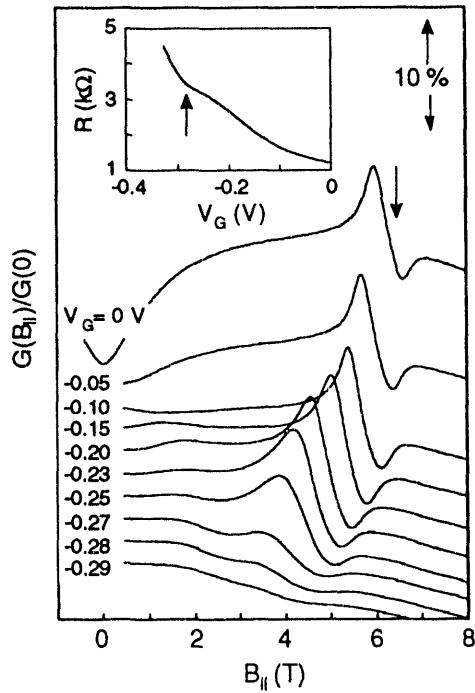


FIG. 1. Normalized  $G_{\parallel}$  vs.  $B_{\parallel}$  of sample A for different  $V_G$ , offset from one another by 2 %. Arrow indicates  $\hbar(k_1+k_2)/ed$  for  $V_G=0$ , with  $d$  from a Hartree self-consistent calculation. Inset:  $B_{\parallel}=0$  resistance vs.  $V_G$ .

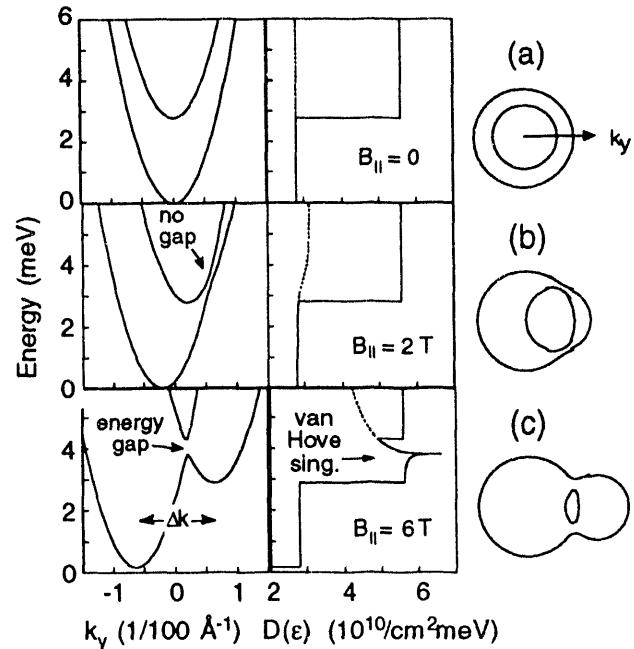


FIG. 2. Calculated dispersion  $\epsilon(k_y)$  (left); calculated density of states  $D(E)$  (middle) for lower energy branch (dotted line) and both energy branches (solid line); and sketch of Fermi surface for  $\mu \approx 5$  meV (right); for  $B_{\parallel}$  = (a) 0 T, (b) 2 T, and (c) 6 T.

having  $w = 140$  Å,  $t = 60$  Å, and unequal QW depths of 280 and 277 meV. (These parameters, while somewhat different from those of the experiment, illustrate the essential physics nicely.) The left column shows the two lowest eigenenergies  $\epsilon_{\pm}(k_y)$ , the middle column the density of states  $D(E)$ , and the right column a sketch of the Fermi surface for chemical potential  $\mu = 5$  meV. The three rows are (a)  $B_{\parallel} = 0$  T, (b) 2 T, and (c) 6 T. At  $B_{\parallel} = 0$  the  $\epsilon_{\pm}(k_y)$  curves are parabolic and  $D(E)$  is constant for each energy branch, with the energy splitting mainly due to the unequal QW depths. The other two  $B_{\parallel}$  values were chosen so that with no coupling the Fermi circles touch tangentially on the inside and outside, respectively, at the same  $\mu = 4$  meV. This corresponds to  $\Delta k_y = k_1 \pm k_2$ , where  $k_1$  and  $k_2$  are the Fermi wavevectors of the top and bottom QWs. When coupling is present, these two cases exhibit two types of anticrossings: In the first, at 2 T, the slopes of  $\epsilon_{\pm}(k_y)$  deviate but do not change sign, changing the group velocity near the anticrossing only slightly. No minigap appears, and the slight changes in  $D(E)$  due to each energy branch cancel one another. Thus the effect on  $G_{\parallel}$  of this type of anticrossing passing through  $\mu$  is negligible. This is in accord with the  $V_G=0$  data of Fig. 1, for which

no features appear at  $B_{\parallel} = \hbar(k_1 - k_2)/ed = XXX$ .

In the second type of anticrossing, at 6 T, the slopes of  $\epsilon_{\pm}(k_y)$  change sign, and a minigap of width  $E_G$  appears.  $E_G$  is insensitive to  $B_{\parallel}$  and  $\approx \Delta$  S A S, the  $B_{\parallel}=0$  symmetric-antisymmetric gap existing when the QW depths (densities) are equal.<sup>5</sup> At the upper gap edge the dispersion is nearly parabolic and a sharp step-like reduction appears in  $D(E)$ . States at the upper gap edge have low velocities and contribute little current, yet make significant contributions to the scattering rates of electrons elsewhere on the Fermi surface. As  $B_{\parallel}$  increases, pushing the upper gap edge through  $\mu$ , electrons are no longer scattered into these states, yielding a sharp decrease in the scattering rates and producing the observed maximum in  $G_{\parallel}$ . The lower gap edge, by contrast, has a saddle-shaped dispersion  $\epsilon(k_x, k_y) = \epsilon_0 + (\hbar k_x)^2/2m^* - (\hbar k_y)^2/2m'$ , where  $\epsilon_0$  is the saddle-point energy, and  $m'$  is determined by the saddle-point

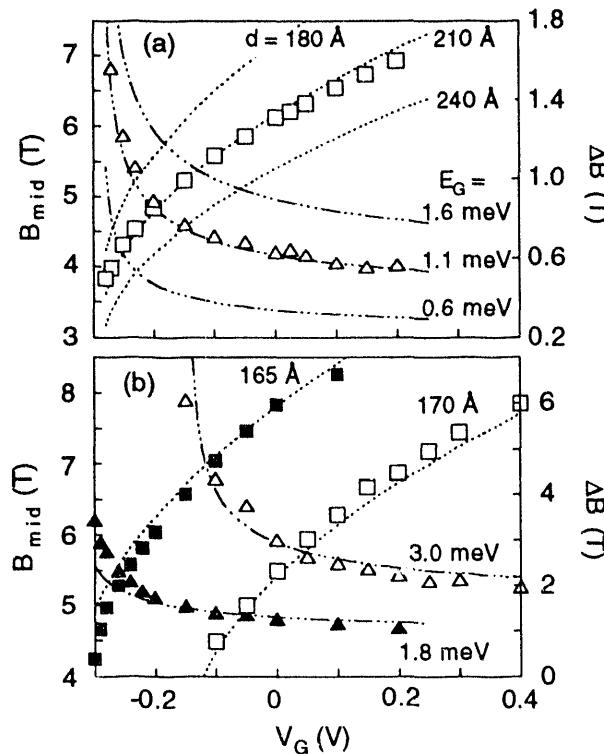


FIG. 3. (a) Plot of  $B_{\text{mid}}$  (squares) and  $\Delta B$  (triangles) for sample A. Using sample A parameters, dotted lines are plots of Eq. (1) for various  $d$ , while dash-dotted lines are plots of Eq. (2) (using the  $d$  obtained from the fit to Eq. 3) for various  $E_G$ . (b) Same as in (a), but for samples B (solid symbols) and C (open symbols), and only showing the best fits.

curvature. This type of dispersion produces a Van Hove singularity at  $\epsilon_0$  of the form  $D(E) \propto -\ln(\epsilon - \epsilon_0)$ . Since the saddle point states have zero group velocity, when  $B_{\parallel}$  is swept and the lower gap edge passes through  $\mu$ , electrons are divergently scattered into states that carry no current, yielding the sharp minimum in  $G_{\parallel}$ .

#### 4. Gate Bias and Minigap Energy

Negatively biasing the gate causes the features in  $G_{\parallel}$  to move to lower  $B_{\parallel}$ . To a first approximation,  $V_G$  linearly changes  $n_1$  while leaving  $n_2$  unchanged. Assuming  $B_{\text{mid}} = (B_{\text{min}} + B_{\text{max}})/2$  corresponds to  $\mu$  lying in mid-gap, or equivalently, to  $\hbar(k_1 + k_2)/ed$ , then

$$B_{\text{mid}} = \left( \sqrt{\frac{C_G}{e}(V_G - V_{\text{depl}})} + \sqrt{n_2} \right) \frac{\hbar\sqrt{2\pi}}{ed} \quad (1)$$

where  $C_G$  is the calculated gate capacitance and  $n_2$  and  $V_{\text{depl}}$  are known from measurements in  $B_{\perp}$ . In Fig. 3 we show fits of Eq. (1) to the  $B_{\text{mid}}$  vs  $V_G$  data, with  $d$  as the only adjustable parameter. Hartree self-consistent calculations (HSCCs) give values for  $d$  of 195, 140, and 180 Å for samples A, B, and C, respectively, in relatively good agreement with the data.

As seen in Fig. 1,  $\Delta B = B_{\text{min}} - B_{\text{max}}$  increases as  $V_G$  is decreased. Using the same model and assuming that  $B_{\text{max}}$  and  $B_{\text{min}}$  occur at  $\hbar[k_1 + k_2 \pm (\Delta k_1 + \Delta k_2)/ed]$ , where  $\Delta k_{1,2} = E_G/(2\partial E/\partial k_{1,2})$  and  $\partial E/\partial k_{1,2}$  is evaluated as  $(2\pi n_{1,2})^{1/2} \hbar^2/m^*$ , we obtain

$$\Delta B = \left[ \left( \frac{C_G}{e}(V_G - V_{\text{depl}}) \right)^{-1/2} + n_2^{-1/2} \right] \frac{E_G m^*}{ed\hbar\sqrt{2\pi}} \quad (2)$$

Fig. 3 shows fits of Eq. (2) to the  $\Delta B$  data, using the values for  $d$  obtained from the fits of Eq. (1).  $E_G$  is the only adjustable parameter. The fits yield  $E_G = 1.1, 1.8$ , and  $3.0$  meV for samples A, B, and C, in fair agreement with the values of 1.4, 2.0, and 3.4 meV obtained from HSCCs, and demonstrating that  $E_G$  can be directly obtained from the data. The model breaks down as  $E_G$  becomes large, so the discrepancy is largest for sample C.

We thank T. R. Castillo for technical assistance. This work was supported by the U.S. Dept. of Energy under Contract DE-AC04-94AL85000.

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4. Many years ago vicinal planes of Si were shown to have a similarly shaped Fermi surface arising by an entirely different mechanism, intervalley coupling. See D. C.

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5. S. K. Lyo, unpublished.

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